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Near breakdown voltage optical beam induced current (OBIC) on 4H-SiC bipolar diode

D. Planson¹⁾, B. Asllani¹⁾, H. Hamad¹⁾, M.-L. Locatelli^{2) 3)}, L. Wei^{2) 3)}, C. Raynaud¹⁾,
P. Bevilacqua¹⁾, L.V. Phung¹⁾

¹⁾ Université de Lyon, INSA Lyon, CNRS UMR 5005, Ampère, Lyon, France

²⁾ Université de Toulouse; UPS, INPT; LAPLACE (Laboratoire Plasma et Conversion d'Energie); 118 route de Narbonne, F-31062 Toulouse cedex 9, France

³⁾ CNRS; LAPLACE; F-31062 Toulouse, France
dominique.planson@insa-lyon.fr

Silicon Carbide (SiC) is an attractive semiconductor material for high power and high temperature applications. In order to reach the expected breakdown voltage, an effective junction termination is required to spread the peripheral electrical field lines. Among different techniques used for periphery protection, Junction Termination Extension (JTE) is often chosen. The key parameters are the accurate dose of the electrically activated implanted dopants and the control of the semiconductor surface charge passivation. SIMS is a destructive way to measure the concentration profile of implanted species in the JTE but it does not allow to distinguish between electrically active dopants and inactive ones. In this paper, OBIC technique is applied to high voltage bipolar diodes to observe the behavior of the periphery protection with respect to the applied reverse voltage. The measured OBIC signal (i.e the current flowing towards the reverse biased junction) is related to the electric field in the bipolar junction space charge.

For voltages near the breakdown voltage, the electric field becomes high; the electron-hole pairs (EHPs) which are generated by the UV beam into the space charge region are accelerated by this high electric field, gained enough kinetic energy to generate new EHPs during a collision with the atoms of the crystalline structure. This is the pre-avalanche regim, which lead to an increase in the OBIC signal [1].

The measurements are realized on a square bipolar diode protected with a single JTE. The anode contact area radius curvature is set at 200 μm , and its total side length is 700 μm . The distance between the metal periphery and the JTE extremity is 250 μm . A cross section of the device is shown in Fig. 1.

The surface of the diode is scanned by the laser beam focused by several lens in a spot of $\sim 10\mu\text{m}$ diameter. A schematic description of the experimental bench is shown in Fig. 2. The measurement is performed in a vacuum chamber able to sustain high voltages up to 3500V. Tests have been carried out at 0 V, but also at higher voltages: 1000 V in Fig. 3 and 2350 V in Fig. 4. Near the breakdown voltage, an increase in the OBIC signal could be observed at the edge of the JTE by the side of the tip. This phenomenon is correlated with the observed luminescence due to the radiative recombination of EHPs generated by avalanche multiplication [2-3], as shown in Fig. 5.

More experimental results (including TCAD simulations) showing the variation of the OBIC signals with the applied reverse voltages will be published in the final paper. Also theoretical simulations will be used to try to estimate the concentration of active dopants.

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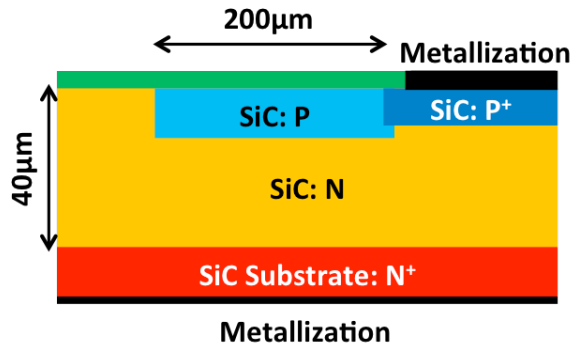


Fig. 1. Cross section of the protected bipolar PiN diode.

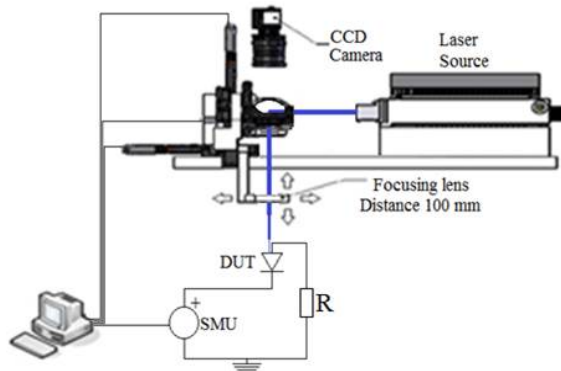


Fig. 2. Schematic of OBIC experimental bench.

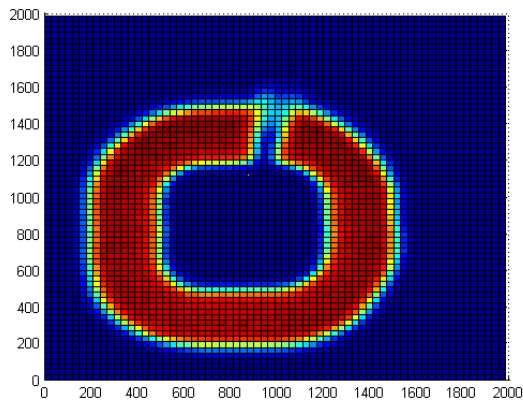


Fig. 3. Top view of OBIC measurement at 1000 V. Position of the tip is deduced from the lower signal level.

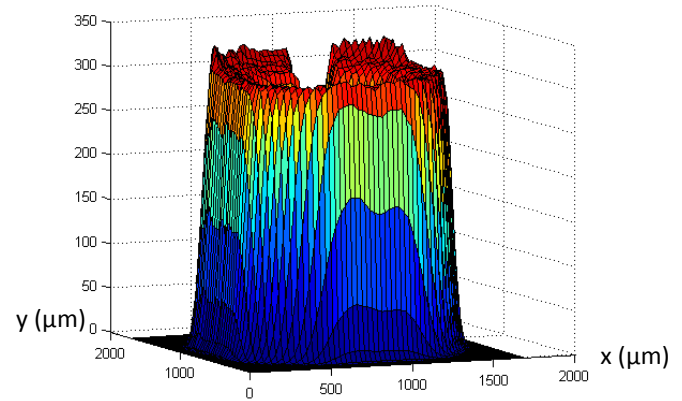


Fig. 4. 2D-cartography of OBIC signal vs. beam position at 2350 V (current is expressed in nA).

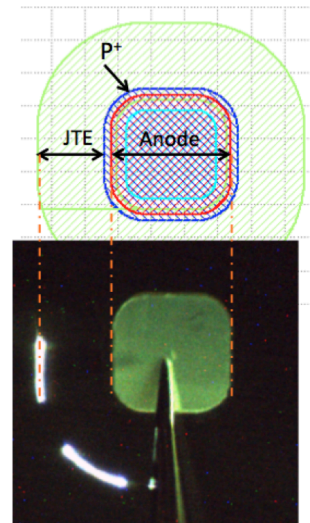


Fig. 5: Luminescence observed at 2351 V.